

PATENT NUMBER

<p>O.I.P.E.</p> <p>SCANNED <i>LR</i> Q.A. <i>WJ</i></p>	<p>PATENT DATE</p>
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APPLICATION NO. 09/976082	CONT/PRIOR	CLASS <del>414</del> 204	SUBCLASS <del>—</del> 192 12	ART UNIT <del>3582</del> 1753	EXAMINER <del>—</del> Ver Steeg
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APPLICANTS Chung-En Kao

TITLE Apparatus and method for self-centering a wafer in a sputter chamber

PTO-2040  
12/89

ISSUING CLASSIFICATION									
ORIGINAL			CROSS REFERENCE(S)						
CLASS		SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
<b>INTERNATIONAL CLASSIFICATION</b>									

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<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>	<b>DRAWINGS</b>		<b>CLAIMS ALLOWED</b>	
	Sheets Drawg.	Figs. Drawg.	Print Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner)		<b>NOTICE OF ALLOWANCE MAILED</b>  	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____  	_____ (Primary Examiner)		<b>ISSUE FEE</b> Amount Due _____ Date Paid _____	
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner)		<b>ISSUE BATCH NUMBER</b>	

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